Structural, morphology and optical properties of Zn\(_{(1-x)}\)Cd\(_x\)O solid solution grown on c-plane sapphire substrate

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Abstract. Zn\(_{(1-x)}\)Cd\(_x\)O solid solutions with a composition ranging from pure ZnO up to x=0.046 have been grown on c-plane sapphire substrates by using metal organic chemical vapor deposition (MO-CVD). The lattice deformation, morphology and optical properties of these films were examined in detail using high resolution X-ray diffraction, atomic force microscopy (AFM) and photoluminescence (PL) as Cd incorporation. Our study reveals significant microstructure modification of Zn\(_{(1-x)}\)Cd\(_x\)O from x\(\geq 0.7\)% but single phase of wurtzite structure is maintained for all films. The PL spectra and the band gap of the Zn\(_{(1-x)}\)Cd\(_x\)O film show red shift to visible light range which is interpreted in terms of band gap modulation due to Cd incorporation. Increase of Cd content leads to the emission broadening with growing lower energy peak (at 10K) and degraded crystallinity.

1 Introduction

ZnO is a II-VI wide band gap (3.3 eV) semiconductor material and has an ability to modulate the band to lower level by alloying with CdO [1]. ZnO has a wurtzite structure (a=3.25 Å, c=5.21 Å). CdO has rock salt (RS) structure (a=4.70 Å). The choice of CdO is based on the fact that ionic radius of Cd\(^{2+}\) (0.95Å) is close to that of Zn\(^{2+}\) (0.74Å), that is, wurtzite phase alloy can be expected in spite of RS structure of CdO. The thermodynamic solubility limit of CdO in ZnO has been reported to be less 2 mol% according to the phase diagram of the ZnO-CdO-P\(_2\)O\(_5\) ternary system [2]. Although good results have been reported for homoepitaxially grown ZnO film [3], the high cost and limited availability of high-quality bulk ZnO substrates preclude their use in mass production environments. On the contrary, sapphire has been chosen as a substrate material due to its relatively low cost, availability in large area wafers. Many studies on the growth of ZnO films have used c-plane sapphire as substrate [4-11]. However, the heteroepitaxy of ZnO on sapphire presents several problems due to differences in their chemical nature, structure and lattices parameters [12]. Furthermore, it is known that the properties of thin solid film are closely related to its microstructure, morphology and surface roughness.

In our work, we are using optical transmission measurements to estimated cadmium incorporation, high-resolution X-ray diffraction (HRXRD), atomic force microscopy (AFM) and photoluminescence to analyses the structural, morphology and optical properties of Zn\(_{(1-x)}\)Cd\(_x\)O solid solutions grown, by metal organic chemical vapor deposition (MO-CVD), on c-plane sapphire substrate as Cd incorporation.

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2 Experiments

The layer is grown in horizontal MO-CVD reactor at atmospheric pressure under N₂ carrier gas. Diethyl-Zinc (DEZn), Dimethyl-Cadmium (DMCd) and tertiary butanol (ter-butanol) are used as Zn, Cd and oxygen precursors, respectively at a growth temperature of 380°C. The growth conditions are described elsewhere [13]. With similar growth parameters, thin films of Zn₁₋ₓCdₓO are directly deposited on c-plane sapphire substrates from Crystec. In order to obtain different compositions of cadmium, the molar flow rate of DMZn was maintained constant while that of DECd was gradually increased from 1 to 10 cc. The growth parameters of a series of five samples with different compositions are listed in table 1.

Table 1. MO-CVD growth parameters, energy band gap (Eₔ) and cadmium content at % of Zn₁₋ₓCdₓO solid solutions deposited on c-plane sapphire substrate.

<table>
<thead>
<tr>
<th>Sample</th>
<th>DEZn Pressure (Pa)</th>
<th>DMCd Pressure (Pa)</th>
<th>Eₔ (eV)</th>
<th>x (%)</th>
</tr>
</thead>
<tbody>
<tr>
<td>M1</td>
<td>13</td>
<td>0</td>
<td>3.26</td>
<td>0</td>
</tr>
<tr>
<td>M2</td>
<td>26</td>
<td>1.5</td>
<td>3.24</td>
<td>0.5</td>
</tr>
<tr>
<td>M3</td>
<td>26</td>
<td>2.5</td>
<td>3.23</td>
<td>0.7</td>
</tr>
<tr>
<td>M4</td>
<td>26</td>
<td>5</td>
<td>3.14</td>
<td>3</td>
</tr>
<tr>
<td>M5</td>
<td>26</td>
<td>10</td>
<td>3.07</td>
<td>4.6</td>
</tr>
</tbody>
</table>

Thickness of ZnCdO film deposited on c-plane sapphire substrate for the different flux ratios used (0, 1, 2.5, 5 and 10 cc) are respectively about 1 µm, 0.6 µm, 2.2 µm, 1.6 µm and 1.4 µm which are measured from cross-section SEM images (Figure 1). They clearly show the non-uniformity of layers thickness.

These samples are characterized by optical transmission measurements at 300K, in the range 310 – 690 nm using a DR/4000U spectrophotometer which can return either the absorption coefficient in arbitrary units or the transmittance in percentage. Figure 2 shows the square (αE) for the Zn₁₋ₓCdₓO solid solution deposited on c-plane sapphire substrate as a function of the photon energy E. The absorption band-edge energy of these samples is estimated by extrapolating linear part of (αE)² to zero. As seen here, the Zn₁₋ₓCdₓO films shows shrinkage in energy gap, which provides supportive evidence that Cd incorporates in ZnO. The cadmium contents (table 1) in these layers deposited on c-plane sapphire substrate are determined from energy band gap (Eₔ) equation established by T. Makino et al. [14], where we have used Eₔ(x=0) deduced from reference sample M1. The highest Cd content reached is 4.6% which is over twice larger than the thermodynamic solubility limit.

Fig. 1. Cross section SEM images of Zn₁₋ₓCdₓO deposited on c-plane sapphire substrates for the different flux ratios used.
High-resolution X-ray diffraction (HRXRD) experiments were performed with D8 discover Bruker AXS diffractometer using CuKα1 radiation at 1.5406 Å. The 2θ-θ scan revealed that all the films had c-axis orientation and wurtzite phase. No indication of any rocksalt phase related to segregate CdO within the layers could be detected. For illustration, XRD measurements of ZnO and Zn_{1-x}Cd_{x}O (x=4.6%) grown on c-plane sapphire are represented in Figure 3. In addition to the ZnO (0002) reflexion and its harmonic, we observe (0006) and (00012) reflexion corresponding to c-plane sapphire substrate.

The mosaicity of the film can be characterized by measuring the corresponding ω-rocking curve of the ZnO (0002) diffraction peak. The full widths at half maximum (FWHMs) of the layers peak are higher than 2° indicating a bad crystalline quality of layers.
determined and summarized in table 2. No layer lattice parameter was determined for sample M2 (x=0.5%) because of the small film thickness.

Table 2. Lattice parameters, c/a ratio and cell volume of Zn$_{1-x}$Cd$_x$O solid solutions deposited on c-plane sapphire as function of cadmium content x.

<table>
<thead>
<tr>
<th>Sample</th>
<th>Cd content (%)</th>
<th>a (Å)</th>
<th>c (Å)</th>
<th>c/a</th>
<th>Cell volume (Å$^3$)</th>
</tr>
</thead>
<tbody>
<tr>
<td>M1</td>
<td>0</td>
<td>3.251</td>
<td>5.206</td>
<td>1.601</td>
<td>47.65</td>
</tr>
<tr>
<td>M2</td>
<td>0.5</td>
<td>-</td>
<td>-</td>
<td>-</td>
<td>-</td>
</tr>
<tr>
<td>M3</td>
<td>0.7</td>
<td>3.251</td>
<td>5.206</td>
<td>1.601</td>
<td>47.65</td>
</tr>
<tr>
<td>M4</td>
<td>3</td>
<td>3.253</td>
<td>5.208</td>
<td>1.601</td>
<td>47.71</td>
</tr>
<tr>
<td>M5</td>
<td>4.6</td>
<td>3.261</td>
<td>5.215</td>
<td>1.599</td>
<td>48.02</td>
</tr>
</tbody>
</table>

Compared to the bulk crystal values (a=3.2495 Å and c=5.2062 Å) [15], there is a slight lattice deformation, assuming that the layer is partially relaxed. The a-, c-axis lengths determined by HRXRD and the cell volume are plotted as functions of Cd content in Figure 4 (a), (b) and (c) respectively. The experimental errors of lattice parameter for all layers are estimated to be 0.003Å. There is a significant change, compared to ZnO layer grown on c-plane sapphire, of a, c layers lattice parameters and the unit cell volume for cadmium content higher than 0.7%. Since for Cd content below 0.7% the Zn$_{1-x}$Cd$_x$O parameter layer mimics that of the ZnO layer. By comparing a and c lattice parameters with those calculated by the evolution equation established by Makino et al. [14], we note that the in-of-plane lattice parameters are similar, however those out-of-plane are different.

At higher cadmium content, the cell volume varied 0.8% for the layer grown on sapphire substrate from that of bulk ZnO. For the film deposited on ZnO, this variation is half of the predicted value (1.6%) obtained by assuming that this difference is caused by the difference in the cation radii of Cd$^{2+}$ (0.95Å) and Zn$^{2+}$ (0.74Å). The ratio (c/a) is between 1.601 and 1.599 for all layers deposited on sapphire which differed very little from those of bulk ZnO (c/a=1.602). The in-plane ($\varepsilon_{xx}$) and out-plane ($\varepsilon_{zz}$) epitaxial strain is calculated and plotted in Figure 5 as function of cadmium content. We have used the lattice parameters of ZnO completely relaxed (bulk) [15]. We can note that the deformation in the growth plan is nearly two times more important than that out of the plane for x>0.7%.
The surface morphology of our film was observed by atomic force microscopy (AFM). All the AFM images were recorded with a Nanoscope III a microscope from digital instruments Inc. in the tapping mode (25°C, in air). The film morphology of Zn_{1-x}Cd_xO grown on c-plane sapphire (scan area 5µm × 5µm) are shown in Figure 6. The AFM images are shown in three and two dimensions to see the difference in the morphology of layers as function of cadmium. The surface roughness of different samples was calculated from AFM images using the software “NanoRule” and the values obtained are presented in table 3.
Upon inspection of the images, ZnO deposited on c-plane sapphire the surface morphology consists of big and faceted grains with rms surface roughness of about 85nm. For solid solutions, the morphology surfaces appear rather rounded grain with a lower surface roughness. However, it is very difficult to correlate the change in surface roughness to that of cadmium content, especially since the film thicknesses are different. The change in grain shape is probably caused by the presence and relative orientations of the different areas of the charges resulted from the atomic arrangement but are disturbed by the incorporation of cadmium and the nature of the surface [16, 17].

Table 3. Roughness surface of Zn_{1-x}Cd_{x}O layers grown on c-plane sapphire for the different cadmium content.
Photoluminescence (PL) measurements were made for these different layers at room temperature using the 325 nm line of He-Cd laser. PL spectra at 10K and 300K of Zn_{1-x}Cd_xO solid solutions grown on c-plane sapphire as function of cadmium content are shown in Figure 7 (a) and (b). The observed PL peak at room temperature of solid solutions shifts to lowers energies corresponding to the excitonic emission band when the cadmium content x increases. The full width at half maximum (FWHM) is about 130 meV for x≤3% and about 150 meV for x=4.6%. The PL spectra at low temperature show the disappearance of the typical fine structure of ZnO [18-24] and the appearance of the shoulder at low energy which becomes more intense and wide as x increases. This is presumably due to larger compositional fluctuation and poorer crystallinity for larger x films. In fact, low temperature PL spectroscopy is a suitable method to detect inhomogeneous potential fluctuation because the photo-excited carriers cannot travel long distance resulting in radiative recombination after relaxation into local potential minima. This same findings were reported by M. Kawasaki [25] with Zn_{1-x}Cd_xO films grown on sapphire (0001) substrates by pulsed laser deposition.

### 3 Conclusion

Zn_{1-x}Cd_xO solid solutions have been grown on c-plane sapphire substrate by metal organic chemical vapor deposition with the DMCd molar ratio range 0 to 10cc. The cadmium mole fraction was determined from energy band gap equation established by T. Makino [14]. Cd content has been seen to increase monotonically with the DMCd molar ratio until about x=4.6% which is significantly larger than thermodynamic solubility limit (2%). The XRD study revealed that all layers exhibit a wurtzite phase and had a c-axis orientation. rocking curve measurement shows a poorer crystalline quality of layer. The microstructure of Zn_{1-x}Cd_xO layer grown on c-plane sapphire substrate compared to the reference sample M1, shows a significant modification from x≥0.7%. The Photoluminescence spectra show a gradual red shift indicating the narrowing of the band gap due to cadmium incorporation. Even though, it is difficult to obtain high-crystalline quality Zn_{1-x}Cd_xO films due to necessary low temperature growth, we can conclude that this material is potential candidate for an active layer in blue LED based on ZnO.

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References